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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/810,435	03/25/2004	Chien-Chou Hung	JCLA11487	9792
23900	7590	04/17/2006	EXAMINER	
J C PATENTS, INC. 4 VENTURE, SUITE 250 IRVINE, CA 92618			MAI, ANH T	
			ART UNIT	PAPER NUMBER
			2832	

DATE MAILED: 04/17/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No. 10/810,435	Applicant(s) HUNG ET AL. (signature)	
	Examiner Anh T. Mai	Art Unit 2832	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 1 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 27 January 2006.
 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-23 is/are pending in the application.
 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
 5) ☐ Claim(s) _____ is/are allowed.
 6) ☒ Claim(s) 1-23 is/are rejected.
 7) ☐ Claim(s) _____ is/are objected to.
 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 a) ☐ All b) ☐ Some * c) ☐ None of:
 1. ☐ Certified copies of the priority documents have been received.
 2. ☐ Certified copies of the priority documents have been received in Application No. _____.
 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413)
Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152) |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Claim Rejections - 35 USC § 102.

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

2. Claims 1-2, 4, 6-8, 10, 12-14, 18, are rejected under 35 U.S.C. 102(e) as being anticipated by Heima [6894598B2].

Heima discloses:

- an inductor formed on a substrate 2 and at least one dielectric layer 44;
- first metal layer 4 and first inductor pattern 11 formed within dielectric layer 44;
- second dielectric layer 43 on the first dielectric layer for covering the first metal layer;
- first inductor pattern 11, first dielectric layer 44, second dielectric layer having plurality of openings wherein second metal layer 42 and second metal pattern 46 are formed;
- second inductor pattern electrically connects with first inductor pattern via connection 53;
- a third metal layer 3 formed on second metal layer and a third inductor pattern 7 on the second inductor pattern;
- the third metal layer electrically connects with the second metal layer;

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- the third inductor pattern electrically connects with the second metal layer via connection 52;
- first inductor pattern and third inductor pattern are not completely overlapping [figures 3B-3C].

With respect to claims 2, 8, 14, first metal layer 3 comprises uppermost metal layer of a multi-layer interconnect on the substrate.

With respect to claims 4, 10, Heima discloses the third metal layer comprises metal pads.

With respect to claims 6, 12, 18, Heima discloses the first, second and third inductor patterns constitute a 3-D inductor structure having an area where the first inductor pattern does not connect third inductor pattern via second inductor pattern [as shown in figure 3C].

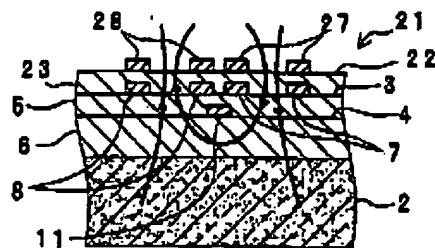
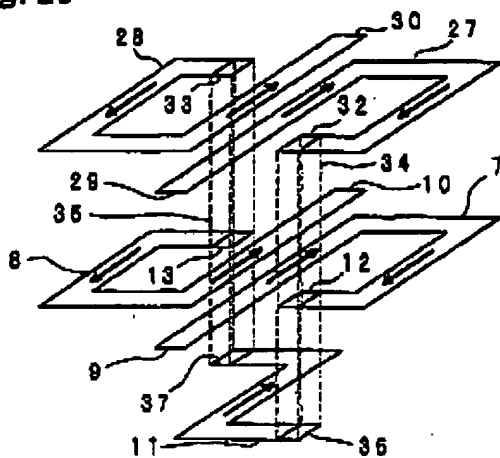


Fig. 2C



Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

4. Claims 3, 5, 9, 11, 15-17, 19-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Heima in view of Furumiya et al. [2003/0146816A1].

Heima discloses the invention as claimed as cited above except for the second metal layer comprising metal plug and the inductor having a symmetric circular-spiral inductor.

Furumiya discloses a first metal conductive layer 1b, second metal conductive layer 13 and third conductive layer 2b and having symmetric circular spiral inductor [figures 11, 7]. At the time of the invention, it would have been obvious to a person of ordinary skill in the art to use the metal plug as taught by Furumiya for the second conductive layer as disclosed by Heima.

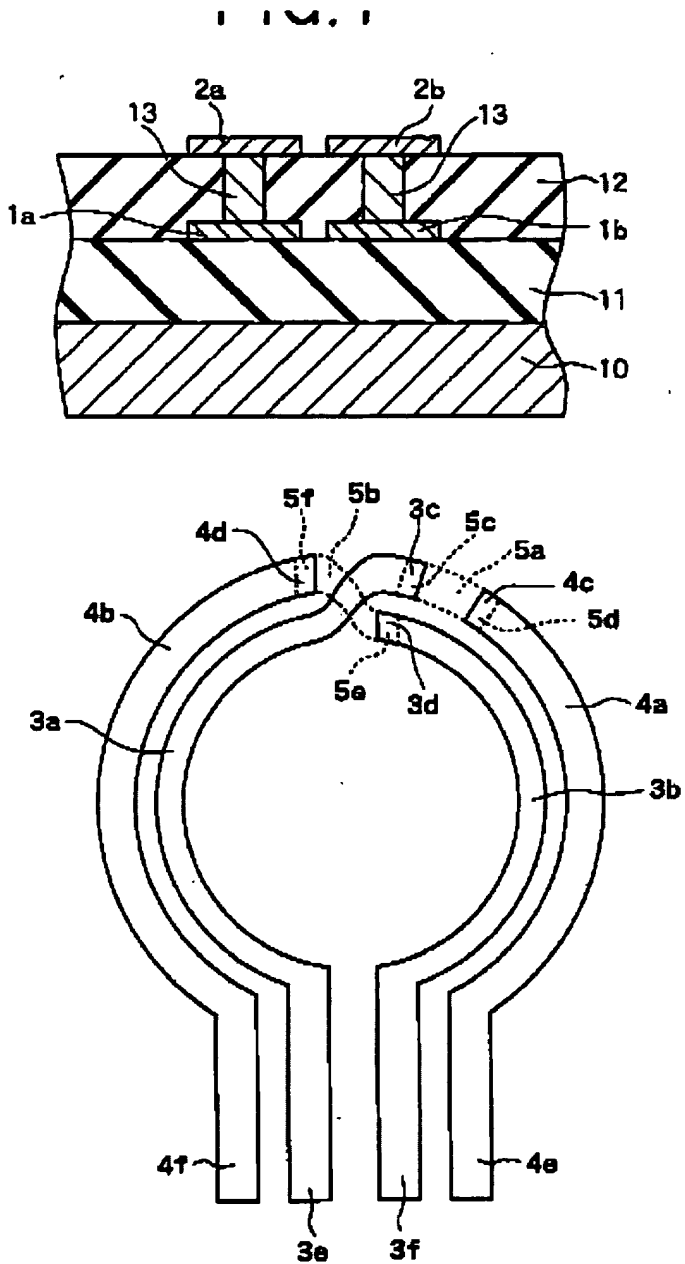
The motivation would have been to connect the first and second conductive layers as shown in figure 7. Therefore, it would have been obvious to combine Furumiya with Heima.

With respect to claim 16, Heima discloses the metal layers made of Al. [col 3, line 46].

With respect to claims 19-23, Furumiya discloses the patterns of first, second, third inductor patterns are different from each other and the bottom surface of second inductor pattern is completely contacts with the first inductor pattern and the top surface of the second conductor pattern is completely in contact with the third inductor pattern [see figure 7] and the first,

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second, and third inductor patterns are completely different from each other [as shown in figure 11].



Response to argument

Applicant's arguments with respect to claims 1-23 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire **THREE MONTHS** from the mailing date of this action. In the event a first reply is filed within **TWO MONTHS** of the mailing date of this final action and the advisory action is not mailed until after the end of the **THREE-MONTH** shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than **SIX MONTHS** from the date of this final action.

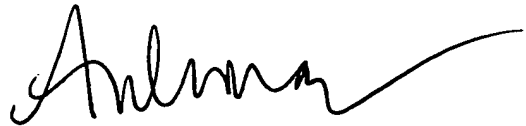
Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anh T. Mai whose telephone number is 571-272-1995. The examiner can normally be reached on 5/4/9 Schedule.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Elvin Enad can be reached on 571-272-1990. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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am

A handwritten signature in black ink, appearing to read 'Anh Mai', with a long, sweeping horizontal stroke extending to the right.

**ANH MAI
PRIMARY EXAMINER**